PATENT AF/IDW 4

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Application of:	Robert J. SMALL et al.	Confirmation No.:	1633
Serial No.:	10/683,730	Art Unit:	2818
Filed:	October 10, 2003	Examiner:	Quoc Dinh HOANG
For:	**CHEMICAL MECHANICAL POLISHING COMPOSITION AND PROCESS**	Attorney Docket No.:	063254-0211-US

OIPE JC104 MAY 10 2005 PATENT & TRADEMARK OFFICE

NOTICE OF APPEAL FROM THE PRIMARY EXAMINER TO THE BOARD OF PATENT APPEALS AND INTERFERENCES

Commissioner for Patents
P.O. Box 1450
Mail Stop AF
Alexandria, VA 22313-1450

Sir:

Applicant hereby appeals to the Board of Patent Appeals and Interferences from the decision dated of the Primary Examiner finally rejecting claims of the above-identified application.

The item(s) checked below are appropriate:

1. ☒ An extension of time for responding to the final rejection for 1 month:
   - ☐ was filed on
   - ☒ is submitted herewith.
2. ☒ A timely response to the final rejection has been filed.
3. ☒ A fee in the amount of $500.00 is:
   - ☒ Required.
   - ☐ Not required (Fee paid in prior appeal).
4. ☐ Applicant has qualified for the 50% reduction in fee for an independent inventor, non-profit organization or small business concern and a fee in the amount of $165.00 is:
   - ☐ Required.
   - ☐ Not required (Fee paid in prior appeal).
5. ☒ The undersigned is the attorney or agent of record.
6. ☒ Please charge the required fee, if any, to Morgan, Lewis & Bockius LLP Deposit Account No. 50-0310. A copy of this sheet is enclosed.

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Respectfully submitted,

Date: May 10, 2005

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